

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Miwa KOZAWA et al.**

Art Unit: **1795**

Application Number: **10/720,097**

Examiner: **Daborah Chacko Davis**

Filed: **November 25, 2003**

Confirmation Number: **4454**

For: **PROCESS FOR FORMING RESIST PATTERN, SEMICONDUCTOR DEVICE
AND FABRICATION THEREOF**

Attorney Docket Number: **032132**

Customer Number: **38834**

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

May 17, 2010

Sir:

Applicant petitions the Commissioner for Patents to extend the time for response to the Office Action dated December 17, 2009 for two months from March 17, 2010 to May 17, 2010.

Attached please find payment of \$490.00 for the cost of the extension of time. If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP

/Kenneth H. Salen/

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